2D Materials: Surfaces, Interfaces, and Defects

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The size reduction and economics of integrated circuits, captured since the 1960's in the form of Moore's Law, is under serious challenge. Current industry roadmaps reveal that physical limitations include reaching aspects associated with truly atomic dimensions, and the cost of manufacturing is increasing such that only 2 or 3 companies can afford leading edge capabilities. To address some of the materials physical limitations, "2D materials" such as graphene, phosphorene, h-BN, and transition metal dichalcogenides have captured the imagination of the electronics research community for advanced applications in nanoelectronics and optoelectronics. Among 2D materials "beyond graphene," some exhibit semiconducting behavior, such as transition-metal dichalcogenides (TMDs), and present useful bandgap properties for applications even at the single atomic layer level. Examples include "MX_2", where M = Mo, W, Sn, Hf, Zr and X = S, Se and Te

In addition to the potentially useful bandgaps at the monolayer thickness scale, the atomically thin layers should enable thorough electric field penetration through the channel, thus enabling superior electrostatic control. Further, with such thin layers, the integration with suitable gate dielectrics can result in a mobility enhancement. From an interface perspective, the ideal TMD channel material should have a dearth of dangling bonds on the surface/interface, resulting in low interface state densities which are essential for efficient carrier transport. The ideal TMD materials have much appeal, but the reality of significant densities of defects and impurities will surely compromise the intrinsic performance of such device technologies. This presentation will examine the state-of-the-art of these materials in view of our research on semiconductor device applications, and the challenges and opportunities they present for electronic and optoelectronic applications. [1]
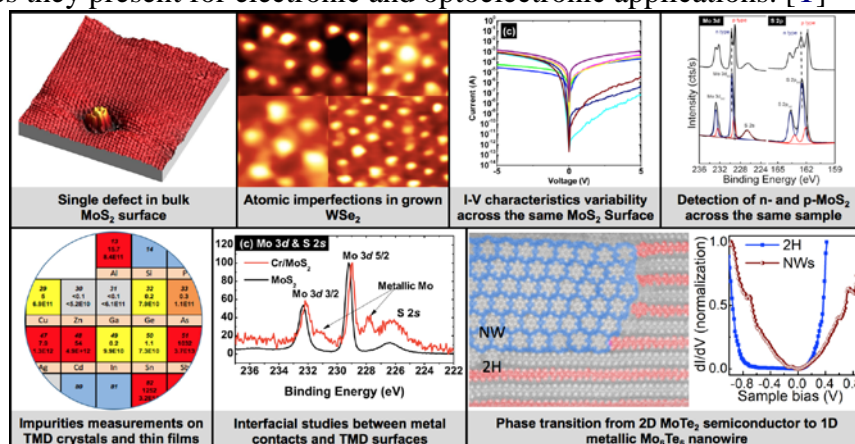

Figure 1. Representative defect issues for 2D TMD materials

1. S. J. McDonnell and R.M.Wallace, *Thin Solid Films*, **616**, 482-501 (2016).

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